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Attorney Docket No. 042390.P10050

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Jm th

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Patent Application of:

Sanjay S. Natarajan, et al.

Serial No. 09/750,734

Filed: December 27, 2000

For: **MULTI-LAYER FILM STACK FOR  
EXTINCTION OF SUBSTRATE  
REFLECTIONS DURING PATTERNING**

Examiner: Gurley, Lynn Ann

Art Unit: 2812

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AMENDMENT AND RESPONSE TO OFFICE ACTION

Box Amendments  
Non-Fee  
Commissioner for Patents  
Washington, D.C. 20231-9998

Dear Sir:

In response to an Office Action having a mailing date of June 19, 2002,  
please amend the above-identified patent application as follows.

IN THE CLAIMS

Please amend the claims as follows:

21 Sub C3  
7. (Amended) The method of claim 1, wherein the dielectric layer comprises a first dielectric layer, the method further comprising introducing a second dielectric layer between the first dielectric layer and an etch stop layer.